Supporting Information

How Carbon Contamination on the Photocatalysts Interferes Performance

Analysis of CO₂ Reduction Reaction

Jiakang You¹, Mu Xiao¹, Siqi Liu¹, Haijiao Lu¹, Peng Chen¹, Zhi Jiang², Wenfeng Shangguan², Zhiliang Wang^{1*}, Lianzhou Wang^{1*}

Nanomaterials Centre, School of Chemical Engineering and Australian Institute for

Bioengineering and Nanotechnology, The University of Queensland, St Lucia, Queensland,

4072, Australia.

Email: zhiliang.wang@uq.edu.au; l.wang@uq.edu.au

Materials

TiO₂ (Sigma-Aldrich, P25 21 nm primary particle size (TEM), \geq 99.5% trace metals basis), and HAuCl₄ • 3H₂O (Sigma-Aldrich, ACS reagent, \geq 49.0% Au basis), NaBH₄ (Sigma-Aldrich, caplets, 98%), CuSO₄ (Sigma-Aldrich, \geq 99%), Melamine (Sigma-Aldrich, \geq 99%), NaOH (Sigma-Aldrich, \geq 98%), Bi₂O₃ (Sigma-Aldrich, \geq 99.9%), V₂O₅ (Thermo Fisher Scientific, \geq 99.6%), SnO₂ (Sigma-Aldrich, \geq 99.9%), nitric acid (Thermo Fisher Scientific, 70%), ethanol (Merk EMSURE[®] absolute for analysis), and ethyl acetate (Sigma-Aldrich, anhydrous, 99.8%) were used without further purification. Deionised (DI) water was used throughout the experiment.

Synthesis of CuO photocatalyst

CuO was prepared using a modified method previously reported.¹ In this process, CuSO₄ (0.81 g) was dissolved in DI water (50 mL) under vigorous stirring at 60 °C for 5 mins to form solution A. NaOH (1.2 g) was dissolved in DI water (5 mL) to form solution B. Solution B was then added dropwise to solution A. Next, the dark precipitate was stirred for another 10 mins, and then cooling to room temperature naturally. Afterwards, the supernatant was removed. The precipitates with CuO particles were centrifuged three times in DI water and dried in an oven at 70 °C overnight.

Synthesis of BiVO₄ photocatalyst

 $BiVO_4$ was prepared using a method previously reported.² Bi_2O_3 and V_2O_5 were mixed in 0.5 M nitric acid solution at a molar ratio of 1:1. The mixture was then stirred at ambient condition for 96 hours. Afterwards, the $BiVO_4$ particles were centrifuged and washed three times in DI water and dried in an oven at 70 °C overnight.

Synthesis of g-C₃N₄ photocatalyst

In a typical synthesis procedure, 20 g of melamine was put into an alumina crucible with a lid and calcined to 550 °C in air for 2 hours. After calcination, $g-C_3N_4$ was obtained.

All inorganic deposition of gold nanoparticles on photocatalysts (TiO₂, CuO, BiVO₄, g-C₃N₄, and SnO₂)

Gold was deposited using a modified all-inorganic method previously reported.³ First, 1.0 g photocatalyst (TiO₂, CuO, and BiVO₄, g-C₃N4, SnO₂) was dispersed in 100 mL DI water. After 30-min ultrasonic treatment, 5 mL HAuCl₄ solution (2 mgAu/mL) was added into the dispersion. Then, 2.539 mL of the 0.1 M freshly prepared solution of NaBH₄ was added into the dispersion under vigorous stirring. After 10-min stirring, the solution was centrifuged and washed thoroughly with DI water for three times. The final product was obtained after drying in the oven at 70 °C overnight. Afterwards, all the as-synthesised materials (except g-C₃N₄, as it is carbon containing material) decorated with gold nanoparticles were heated at 450 °C under air for 2 hours.

Characterisation

X-ray and ultraviolet photoelectron spectroscopy (XPS and UPS) with an Al K α X-ray radiation source was used to characterise the chemical composition of the material. The UVvis absorption spectra were obtained using a JASCO V-650 spectrophotometer. The crystalline phase of the samples was characterised by X-ray powder diffraction (Rigaku, Miniflex, benchtop powder XRD instrument) with Cu K α (λ =0.15406 nm) radiation. A transmission electron microscope (Hitachi HT 7700 120kV TEM) is used to observe the gold nanoparticle distribution on the P25.

Analysis method for UPS

The UPS data was analysed according to the literature.⁴ The work functions (WF) of the samples were obtained by subtracting the cutoff binding energy (E_{cutoff}) with the radiative photon energy (He I α at 21.22 eV). The distance between WF and valence band (VB) edge was defined as E_{VBM} . The VB edges of different photocatalysts (TiO₂, CuO and BiVO₄) can be acquired by using the following equations S1 and S2:

$$WF = E_{cutoff} - 21.22 \ eV \tag{1}$$

$$VB = WF - E_{VBM} = E_{cutoff} - 21.22 \ eV - E_{VBM}$$

$$\tag{2}$$

Combining the bandgap value (E_g) acquired from the UV-vis absorption spectra, the conduction band (CB) edges of photocatalysts can be obtained by using the following equation S3:

$$CB = E_g + VB = E_g + E_{cutoff} - 21.22 - E_{VBM}$$
(3)

Photocatalytic performance test

Firstly, 12.5 mg Au/P25 was spread on the home-made glass holder. The glass holder with Au/P25 was baked at 100 °C for 30 mins prior to the photocatalytic performance test. Then, the glass holder was put in a metal reactor (purchased from Perfectlight Technology Co., Ltd, Beijing). 1 mL DI water was added into the reactor as the reductant. The reactor was then sealed and purged with argon gas for 30 mins. After that, high-purity CO_2 was purged for 30 mins. Before illumination, 1 mL of the gas from the reactor was injected into the gas chromatography (GC-2014, Shimadzu) to record the background information. The reactor was illuminated by a 300 W Xe lamp (lamp current:19 A, full spectrum, Perfectlight Technology Co., Ltd). The impact of organic solvent vapour (i.e.,) was investigated by adding 1 μ L of ethanol the reactor.

Oxygen Plasma Treatment

The plasma cleaning provides nanoscale surface cleaning of materials for various applications. In this work, O₂ plasma treatment is used to remove contaminants (especially carbon-based species) from the surface of photocatalysts. In detail, the photocatalyst loaded on a glass support is put into the chamber of the Harrick Plasma expanded plasma cleaner (PDC-001 and PDC-002) with a power of 30 W for 30 minutes.



Supporting Figures

Figure S1. XRD pattern of Au/TiO₂ (P25) and TiO₂ (P25).



Figure S2. TEM image of Au/TiO₂. Gold nanoparticles were indicated by red circles.



Figure S3. UPS spectra of (a)-(b) TiO₂ (P25), (c)-(d)) CuO, (e)-(f) BiVO₄.



Figure S4. Determining the band gap of (a) TiO₂ (P25), (b) CuO, and (c) BiVO₄ by K-M

function.



Figure S5. Photocatalytic performance of Au/TiO₂ with different solvents: Hydrogen production. MSP: Mass Specific Production Rate.



Figure S6. Controlled experiments under argon and CO₂ atmospheres: Hydrogen production. MSP: Mass Specific Production Rate.



Figure S7. Photocatalytic CO₂RR performance over TiO₂, CuO and BVO: Hydrogen production. MSP: Mass Specific Production Rate.



Figure S8. Photocatalytic CO_2RR performance of SnO_2 (a) CO production; (b) CH_4 production. (No hydrogen production was detected.) MSP: Mass Specific Production Rate.



Figure S9. Photocatalytic performance of pure TiO₂ with different solvents (a) CO production;(b) CH₄ production; and (c) H₂ production. MSP: Mass Specific Production Rate.



Figure S10. Controlled experiments before and after plasma treatment under argon and CO₂ atmospheres: Hydrogen production. MSP: Mass Specific Production Rate.

Table S1. Surface carbon content of TiO₂, CuO, and BiVO₄ based on XPS survey scan.

| Material | Surface carbon content At% | Surface carbon content wt% |
|------------|----------------------------|----------------------------|
| TiO2 (P25) | 27.21 | 14.96 |
| CuO | 38.74 | 26.02 |
| BiVO4 | 34.88 | 8.44 |
| | | |

Table S2. Selectivity analysis of CO, CH₄, and H₂ with different solvents for Au/TiO₂.

| Water only | With 1 µL EtOH |
|----------------------|---|
| $4.54\% \pm 0.58\%$ | $0.2\% \pm 0.02\%$ |
| 42.17% ± 5.35% | $57.03\% \pm 0.12\%$ |
| $53.29\% \pm 5.93\%$ | $42.76\% \pm 0.10\%$ |
| | Water only 4.54% ± 0.58% 42.17% ± 5.35% 53.29% ± 5.93% |

References

- 1. R. Li, X. Tao, R. Chen, F. Fan and C. Li, *Chem. Eur. J.*, 2015, **21**, 14337-14341.
- 2. H. Wu, R. Irani, K. Zhang, L. Jing, H. Dai, H. Y. Chung, F. F. Abdi and Y. H. Ng, *ACS Energy Lett.*, 2021, **6**, 3400-3407.
- 3. M. V. Dozzi, L. Prati, P. Canton and E. Selli, *Phys. Chem. Chem. Phys.*, 2009, **11**, 7171-7180.
- 4. P. Chen, Z. Wang, S. Wang, M. Lyu, M. Hao, M. Ghasemi, M. Xiao, J.-H. Yun, Y. Bai and L. Wang, *Nano Energy*, 2020, **69**, 104392.